## **CLAIMS**

## What is claimed is:

1. A film-forming composition comprising a hydrolysis product and/or a condensation product of a compound having a repeating unit represented by Formula (1) below

$$P = \begin{pmatrix} H & R^{6} \\ | & | \\ C & C \\ | & | \\ R^{5} & (L^{1} - Y^{1}) \end{pmatrix}_{X} \begin{pmatrix} H & R^{8} \\ | & | \\ C & C \\ | & | \\ R^{7} & (L^{2} - Y^{2}) \end{pmatrix}_{Y} Q \qquad (1)$$

(in the formula, at least one of P and Q is a silane coupling group represented by -L³-Si(R³)<sub>m</sub>(OR⁴)<sub>3-m</sub>, R³, R⁴, R⁵, R⁶, Rⁿ, and R³ independently denote a hydrogen atom or a hydrocarbon group having 1 to 8 carbons, m denotes 0, 1, or 2, x denotes a range of 100 to 1 mol %, y denotes a range of 0 to 99 mol %, and P and Q denote terminal groups; L¹, L², and L³ independently denote a single bond or a divalent organic linking group, Y¹ and Y² independently denote -N(R³)(R¹0), -OH, -NR°COR³, -CON(R³)(R¹0), -OR³, -CONR³₂, -COR³, -CO₂M, -COOR³, or -SO₃M, in which R⁰, R³, and R¹0 independently denote a hydrogen atom or an alkyl group having 1 to 8 carbons, R⁰ and R³ may form a ring structure, and M denotes a hydrogen atom, an alkali metal, an alkaline earth metal, or onium).

- 2. The film-forming composition according to Claim 1, wherein  $L^1$  and  $L^2$  in Formula (1) are single bonds and  $L^3$  is an alkylenethio group.
- 3. The film-forming composition according to Claim 1, wherein the composition comprises a hydrolysis product and/or a condensation product of a compound represented by Formula (1) and at least one type of silane compound selected from the group consisting of a compound represented by Formula (2) below and a compound represented by Formula (3) below

$$Si(OR^{11})_4$$
 (2)  
(in the formula,  $R^{11}$  denotes a monovalent organic group)  
 $R^{12}_aSi(OR^{13})_{4-a}$  (3)

(in the formula, R<sup>12</sup> denotes a hydrogen atom, a fluorine atom, or a monovalent organic group, R<sup>13</sup> denotes a monovalent organic group or an organosilicon group, and a denotes an integer of 1 or 2).

- 4. The film-forming composition according to Claim 3, wherein R<sup>11</sup> in Formula (2) is an alkyl group having 1 to 5 carbons.
- 5. The film-forming composition according to Claim 3, wherein R<sup>12</sup> and R<sup>13</sup> in Formula (3) independently denote an alkyl group having 1 to 5 carbons.
- 6. A process for producing a film-forming composition, the process comprising a step of hydrolyzing and/or condensing a compound having a repeating unit represented by Formula (1) below

$$P = \begin{pmatrix} H & R^{6} \\ C & C \\ R^{5} & (L^{1}-Y^{1}) \\ X \end{pmatrix} \begin{pmatrix} H & R^{8} \\ C & C \\ R^{7} & (L^{2}-Y^{2}) \\ Y \end{pmatrix}$$
 (1)

(in the formula, at least one of P and Q is a silane coupling group represented by  $-L^3-Si(R^3)_m(OR^4)_{3-m}$ ,  $R^3$ ,  $R^4$ ,  $R^5$ ,  $R^6$ ,  $R^7$ , and  $R^8$  independently denote a hydrogen atom or a hydrocarbon group having 1 to 8 carbons, m denotes 0, 1, or 2, x denotes a range of 100 to 1 mol %, y denotes a range of 0 to 99 mol %, and P and Q denote terminal groups;  $L^1$ ,  $L^2$ , and  $L^3$  independently denote a single bond or a divalent organic linking group,  $Y^1$  and  $Y^2$  independently denote  $-N(R^9)(R^{10})$ , -OH,  $-NR^0COR^9$ ,  $-CON(R^9)(R^{10})$ ,  $-OR^9$ ,  $-CONR^9_2$ ,  $-COR^9$ ,  $-CO_2M$ ,  $-COOR^9$ , or  $-SO_3M$ , in which  $R^0$ ,  $R^9$ , and  $R^{10}$  independently denote a hydrogen atom or an alkyl group having 1 to 8 carbons,  $R^0$  and  $R^9$  may form a ring structure, and M denotes a hydrogen atom, an alkali metal, an alkaline earth metal, or onium).

7. The process for producing a film-forming composition according to Claim 6, wherein the process comprises a step of hydrolyzing and/or condensing a compound represented by Formula (1) and at least one type of silane compound selected from the group consisting of a compound

represented by Formula (2) below and a compound represented by Formula (3) below

$$Si(OR^{11})_4$$
 (2)

(in the formula, R<sup>11</sup> denotes a monovalent organic group)

$$R^{12}_{a}Si(OR^{13})_{4-a}$$
 (3)

(in the formula, R<sup>12</sup> denotes a hydrogen atom, a fluorine atom, or a monovalent organic group, R<sup>13</sup> denotes a monovalent organic group or an organosilicon group, and a denotes an integer of 1 or 2).

8. A porous insulating film formed by using a film-forming composition comprising a hydrolysis product and/or a condensation product of a compound having a repeating unit represented by Formula (1) below

$$P = \begin{pmatrix} H & R^{6} \\ C & C \\ R^{5} & (L^{1} - Y^{1}) \end{pmatrix}_{X} \begin{pmatrix} H & R^{8} \\ C & C \\ R^{7} & (L^{2} - Y^{2}) \end{pmatrix}_{Y}$$
 (1)

(in the formula, at least one of P and Q is a silane coupling group represented by  $-L^3$ -Si(R³)<sub>m</sub>(OR⁴)<sub>3-m</sub>, R³, R⁴, R⁵, R⁶, R³, and R³ independently denote a hydrogen atom or a hydrocarbon group having 1 to 8 carbons, m denotes 0, 1, or 2, x denotes a range of 100 to 1 mol %, y denotes a range of 0 to 99 mol %, and P and Q denote terminal groups;  $L^1$ ,  $L^2$ , and  $L^3$  independently denote a single bond or a divalent organic linking group, Y¹ and Y² independently denote  $-N(R^9)(R^{10})$ , -OH,  $-NR^0COR^9$ ,  $-CON(R^9)(R^{10})$ ,  $-OR^9$ ,  $-CONR^9_2$ ,  $-COR^9$ ,  $-CO_2M$ ,  $-COOR^9$ , or  $-SO_3M$ , in which  $R^0$ ,  $R^9$ , and  $R^{10}$  independently denote a hydrogen atom or an alkyl group having 1 to 8 carbons,  $R^0$  and  $R^9$  may form a ring structure, and M denotes a hydrogen atom, an alkali metal, an alkaline earth metal, or onium).

- 9. The porous insulating film according to Claim 8, wherein L<sup>1</sup> and L<sup>2</sup> in Formula (1) are single bonds and L<sup>3</sup> is an alkylenethio group.
- 10. The porous insulating film according to Claim 8, wherein the filmforming composition comprises a compound represented by Formula (1) and at

least one type of silane compound selected from the group consisting of a compound represented by Formula (2) below and a compound represented by Formula (3) below

$$Si(OR^{11})_4$$
 (2)

(in the formula, R<sup>11</sup> denotes a monovalent organic group)

$$R_{a}^{12}Si(OR^{13})_{4-a}$$
 (3)

(in the formula, R<sup>12</sup> denotes a hydrogen atom, a fluorine atom, or a monovalent organic group, R<sup>13</sup> denotes a monovalent organic group or an organosilicon group, and a denotes an integer of 1 or 2).

- 11. The porous insulating film according to Claim 10, wherein R<sup>11</sup> in Formula (2) is an alkyl group having 1 to 5 carbons.
- 12. The porous insulating film according to Claim 10, wherein R<sup>12</sup> and R<sup>13</sup> in Formula (3) independently denote an alkyl group having 1 to 5 carbons.